



DSW

**PATENT APPLICATION**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of

Docket No: Q78871

Takashi CHUMAN, et al.

Appln. No.: 10/750,975

Group Art Unit: 1763

Confirmation No.: 1860

Examiner: Robert P. Culbert

Filed: January 05, 2004

For: MASK USED FOR LAYER FORMATION AND PROCESS OF MAKING THE MASK

**RESPONSE TO RESTRICTION REQUIREMENT**

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450  
Sir:

In response to the Restriction Requirement, dated March 06, 2006, Applicants elect Group I, claims 1-9 for examination. This election is made without traverse.

Applicants reserve the right to file a Divisional Application directed to non-elected claims.

The USPTO is directed and authorized to charge all required fees, except for the Issue Fee and the Publication Fee, to Deposit Account No. 19-4880. Please also credit any overpayments to said Deposit Account.

Respectfully submitted,

A handwritten signature of Darryl Mexic.

Darryl Mexic  
Registration No. 23,063

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**23373**  
CUSTOMER NUMBER

Date: April 5, 2006